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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : Confirmation No. 4033  
Isao NAKATANI et al. : Docket No. 2001-1048A  
Serial No. 09/910,854 : Group Art Unit 1765  
Filed July 24, 2001 : Examiner L. Umez-Eroni

MASKING MATERIAL FOR DRY ETCHING

ADDITIONAL CLAIMS FEE TRANSMITTAL LETTER

Assistant Commissioner for Patents,  
Washington, DC 20231

Sir:

THE COMMISSIONER IS AUTHORIZED  
TO CHARGE ANY DEFICIENCY IN THE  
FEE FOR THIS PAPER TO DEPOSIT  
ACCOUNT NO. 23-0975.

Transmitted herewith is an Amendment in the above-identified application. Additional fees required as a result of this Amendment are calculated as follows:

	SMALL ENTITY	LARGE ENTITY
Total Claims exceeding 20 (not already paid for): 15 x	(\$ 9 = \$)	or (\$18 = \$270)
Indep. Claims exceeding 3 (not already paid for): 8 x	(\$42 = \$)	or (\$84 = \$672)
[ ] Multiple Dep. Claim(s) (if there previously were none):	+ (\$140 = \$)	or (\$280 = \$)
Total Additional Fee =	<u>\$</u>	<u>\$942.00</u>

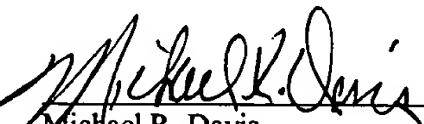
[ ] Small entity status of this application is established by the verified statement under 37 C.F.R. 1.9 and 1.27 which  
[ ] is enclosed or  
[ ] has been previously submitted.

[X] A check in the amount of \$942.00 is enclosed.

[ ] Please charge Deposit Account No. 23-0975 the amount of \$ to cover additional fee. The Commissioner is authorized to charge any deficiency associated with this communication or to credit any overpayment to the Deposit Account. The original and two copies of this document are enclosed.

Respectfully submitted,

Isao NAKATANI et al.

By:   
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February 24, 2003



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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : Confirmation No. 4033  
Isao NAKATANI et al. : Docket No. 2001-1048A  
Serial No. 09/910,854 : Group Art Unit 1765  
Filed July 24, 2001 : Examiner L. Umez-Eronini

MASKING MATERIAL FOR DRY ETCHING

AMENDMENT

Assistant Commissioner for Patents,  
Washington, D.C.

THE COMMISSIONER IS AUTHORIZED  
TO CHARGE ANY DEFICIENCY IN THE  
FEE FOR THIS PAPER TO DEPOSIT  
ACCOUNT NO. 23-0975.

Sir:

Responsive to the Office Action of August 22, 2002, the time for responding thereto being extended for three months in accordance with a Petition for Extension of Time submitted herewith, please amend the above-identified application as follows:

In the Claims:

Kindly amend claim 1 as follows:

A 1 1. (Amended) A masking material for dry etching of a magnetic material by using a mixed gas of carbon monoxide and a nitrogenous compound as etching gas, which comprises a metal having a specific physical property that its melting or boiling point, when it is converted into a nitride or carbide is higher than that of in the form of single metal.

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02 FC:1201  
03 FC:1202

672.00 OP  
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